## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

re Appln. of: Kenichi Mitsumori ET AL.

Appln. No.:

10/801,476

Filed:

March 16, 2004

For:

ULTRASONIC VIBRATOR, WET-TREATMENT NOZZLE,

AND WET-TREATMENT

**APPARATUS** 

Attorney Docket No: 9281-4823

Examiner: Not yet assigned

Art Unit:

1746

## **INFORMATION DISCLOSURE STATEMENT**

In accordance with the duty of disclosure under 37 C.F.R. §1.56 and §§1.97-1.98, and more particularly in accordance with 37 C.F.R. §1.97(b), Applicants hereby cite the following reference(s):

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